Special Issue

Synthesis and Applications of Nanomaterials

Message from the Guest Editor

This Special Issue on the "Synthesis and Applications of Nanomaterials" seeks high-quality papers focusing on recent advances in the preparation of nanomaterials, their characterization, and their technological applications. The topics include but are not limited to the following:

- New methods for the preparation of nanoparticles or nano-assemblies;
- Novel processes for the creation of nanostructured coatings or solids;
- Technological applications of nanomaterials;
- New approaches to modeling and explaining the physical or chemical properties of nanomaterials;
- Characterization of the unique properties of nanomaterials.

Guest Editor

Prof. Dr. Keith J. Stine

Department of Chemistry and Biochemistry, University of Missouri–Saint Louis, Saint Louis, MO 63121, USA

Deadline for manuscript submissions

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Editorial Office MDPI, Grosspeteranlage 5 4052 Basel, Switzerland Tel: +41 61 683 77 34 processes@mdpi.com

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Message from the Editor-in-Chief

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Editor-in-Chief

Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

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